
The Mechanical Performance of Sn-Pb Solder Joints on LTCC Substrates

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Introduction

- ◆ The development and operational sustainment of down hole **renewable (geothermal)** and **non-renewable (fossil fuel)** energy resources will be challenged by increasingly higher costs factors:
 - Site preparation (\$B)
 - Loss of site operations (\$M/day)
 - Liability – environmental restoration (\$B)



Courtesy of Dept. of Energy



Courtesy of Dept. of Energy



Courtesy of NASA

Introduction

- ◆ Downhole **sensor electronics** can significantly improve the efficiency and reliability of well exploration and production.
- ◆ Oil, gas, and geothermal wells present some of the **harshest service conditions** for electrical equipment.
 - Temperatures: 300°C continuous; 350°C peak
 - Pressures: 15,000 to 30,000 psi
 - Vibration: PDS (g^2/Hz), 0.01 – 0.1 (0.6 – 3 kHz)
 - Corrosion: H_2S , H_2 , brine, superheated steam.

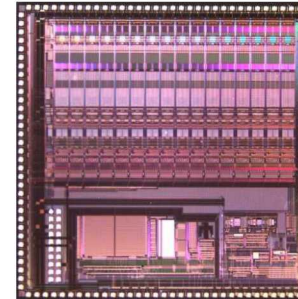


Courtesy of Sandia National Labs.

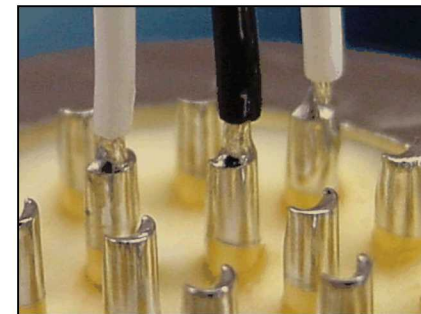
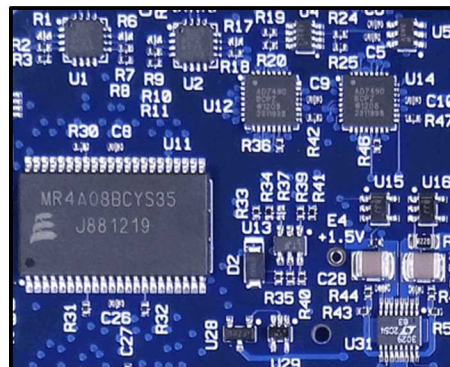
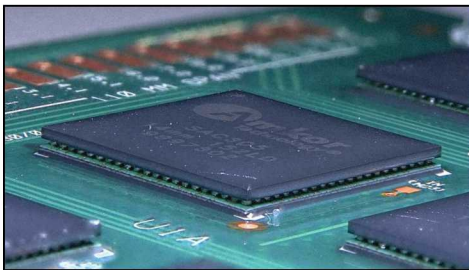
Introduction

- ◆ Advances have been made in the development of high temperature, **electronic components**.

- Increased functionality enhances the information flow from the hole to the field engineer.



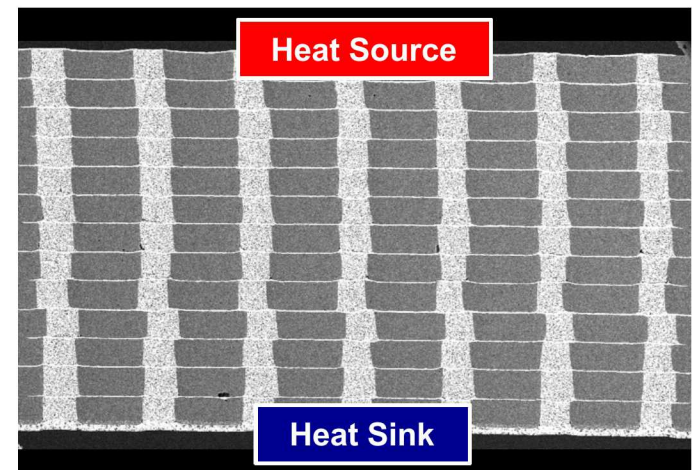
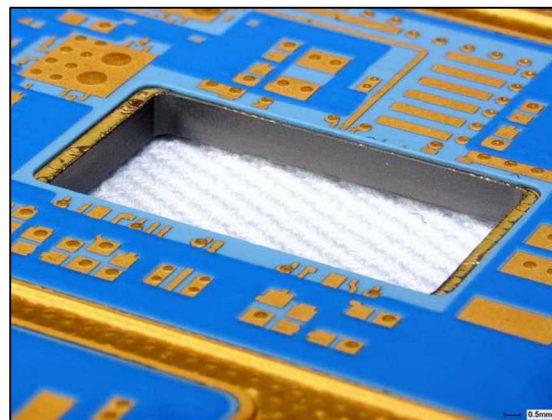
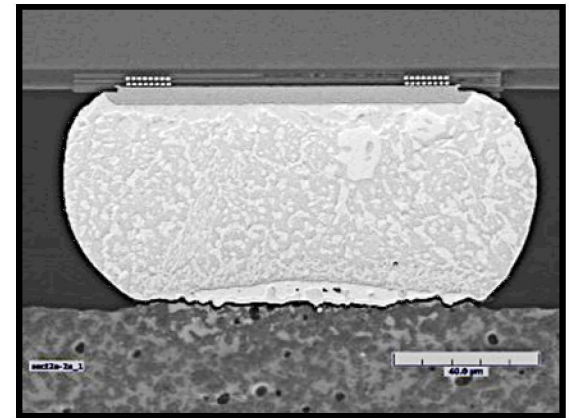
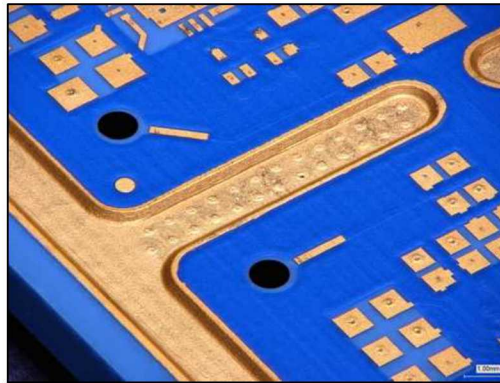
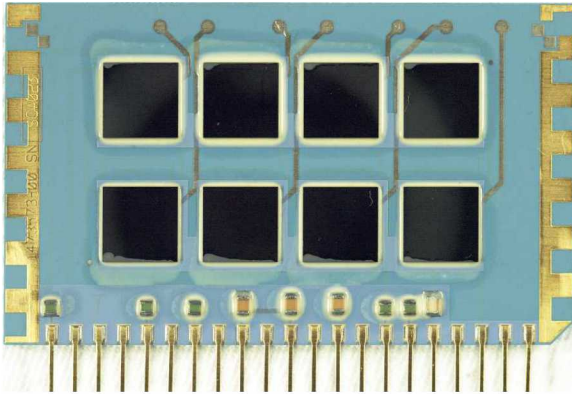
- ◆ However, the benefits to well production can only be realized with similar advances in **electronic packaging technology**.



Organic printed circuit boards are approaching their mechanical and temperature limitations vis-a-vis downhole environments.

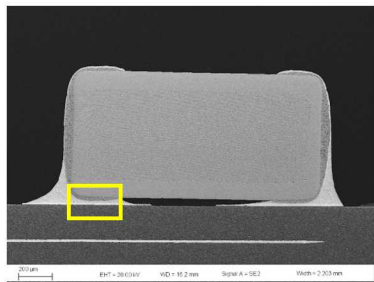
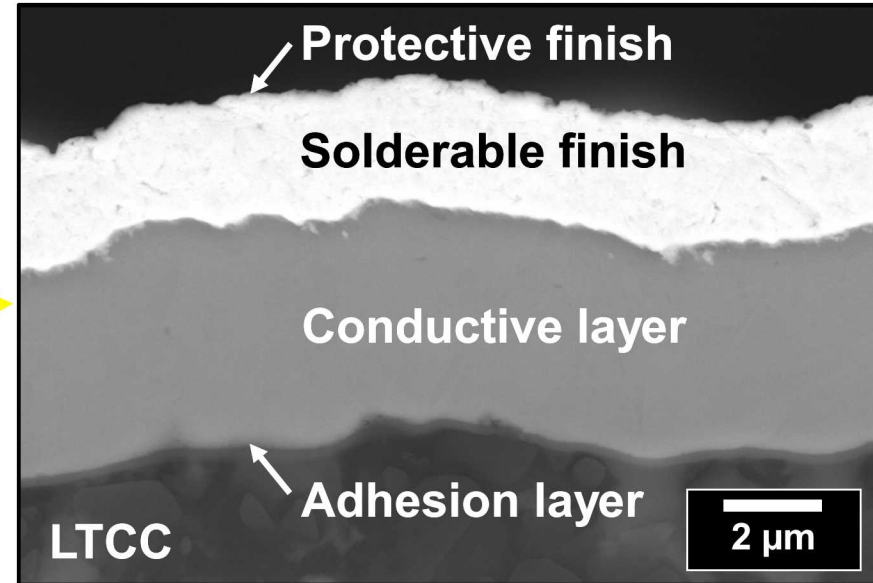
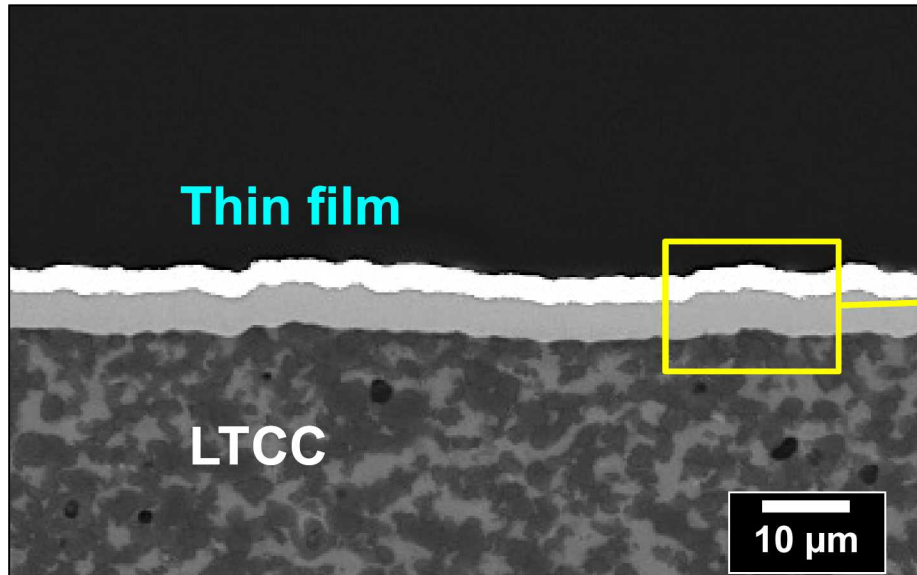
Introduction

- ◆ **Low-temperature co-fired ceramic (LTCC)** technology can provide the functionality of (organic) printed circuit boards *as well as withstand the high-temperature service of downhole conditions.*

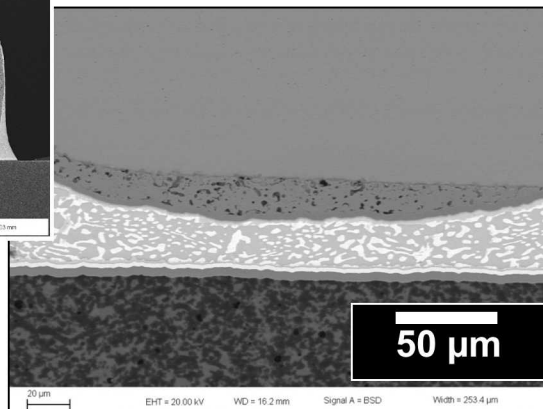


Introduction

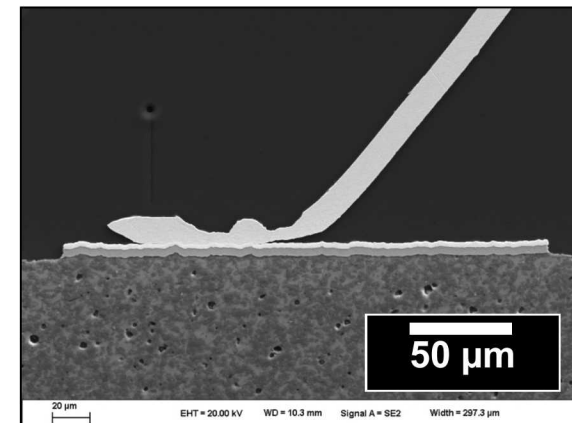
- ◆ **Thin film conductors** provide the *interconnection technology*.



Solderable



**Wire and ribbon
bondable**



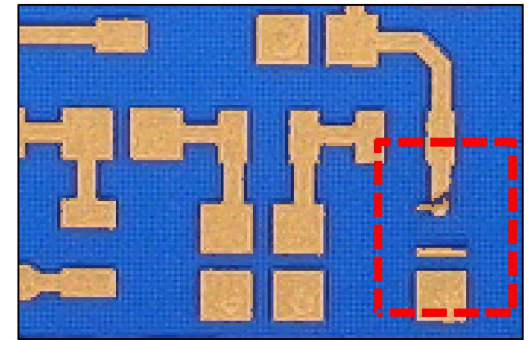
Path-Forward

◆ Problem:

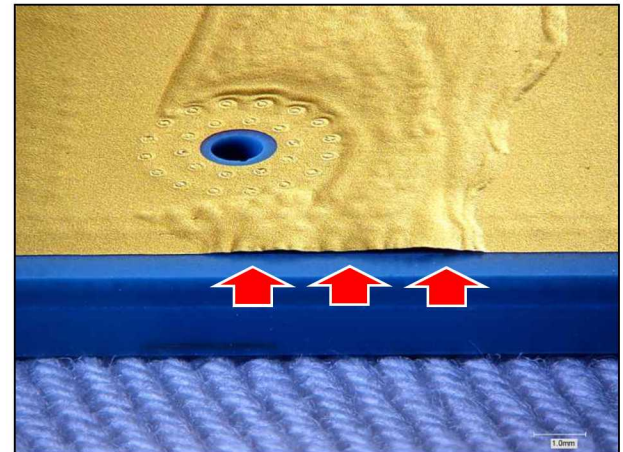
Thin film performance and reliability are sensitive to numerous factors:

- Choice of layers (the “stack”)
- Interface adhesion
- Surface contamination

Cost-effective product yields necessitate a means to optimize the performance of thin films on LTCC.



Delamination defects



◆ Objective:

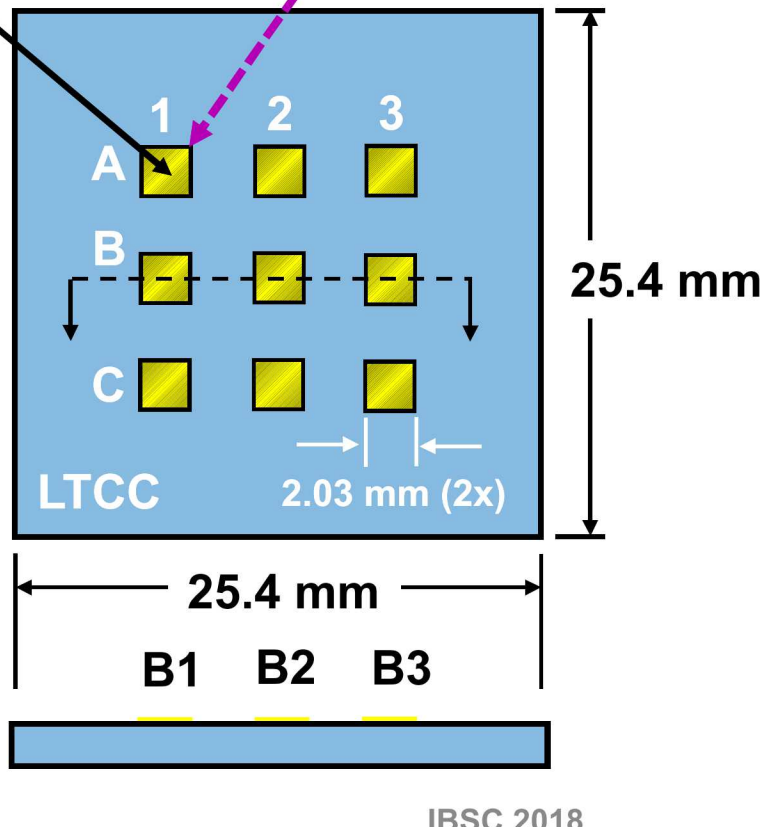
Develop a test methodology and assess the fundamental strength of solder joints made to thin films on LTCC.

Experimental Procedure

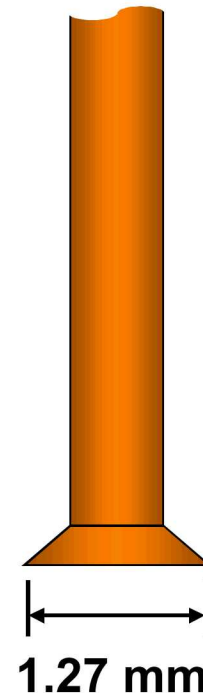
- ◆ A **pin pull test** was developed to measure the tensile strength of **solder joints** made to thin film conductors on LTCC substrates.

The pattern was created by evaporation of the thin film through an aperture mask.

Pull test site
(thin film)

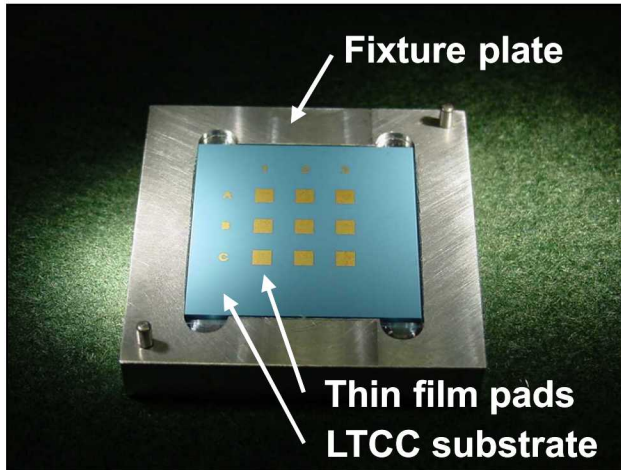


Cu pin



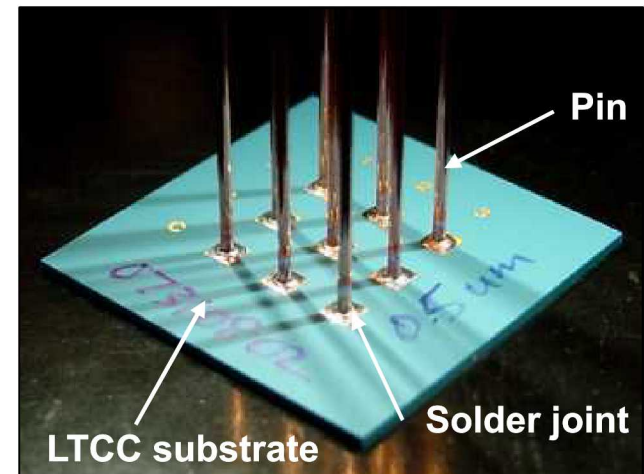
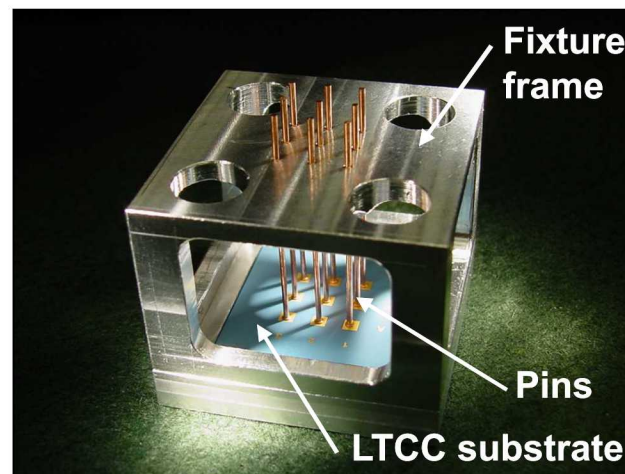
Experimental Procedure

- ◆ The test assembly was fabricated by soldering a pin to each of the nine (9) thin film pads, using a conduction furnace.



Substrate is placed on the fixture plate.

Fixture frame and pins are put into place.



Completed test specimen

Experimental Procedure

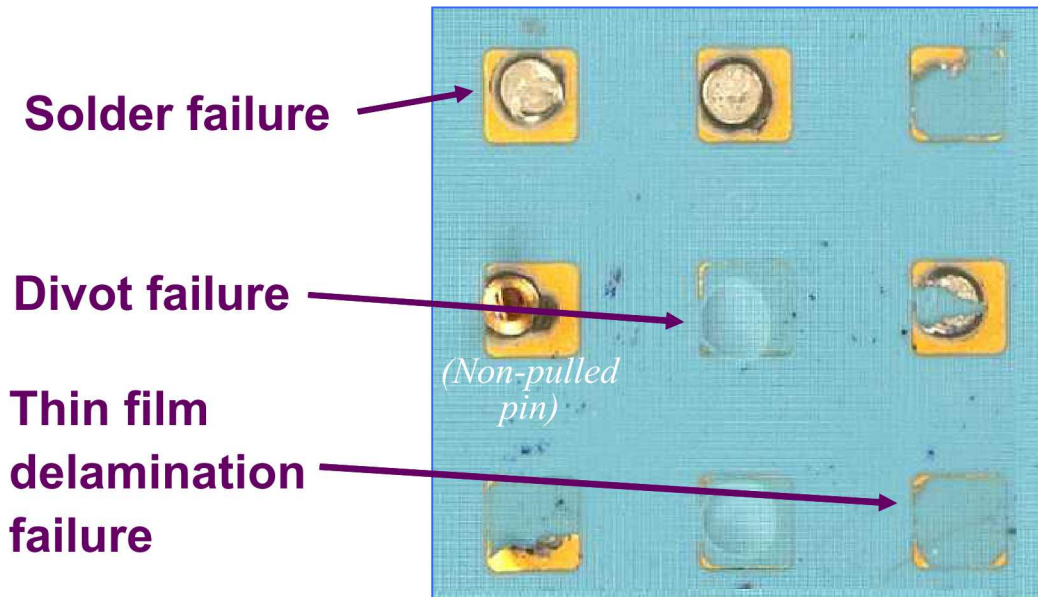
- ◆ The low-temperature, co-fired ceramic (LTCC) substrate is fabricated from the **DuPont™ 951 tape***
- ◆ The thin film is ... **0.20 Ti/W - 4.0 Cu - 2.0 Pt - 0.38 Au (μm)**
- ◆ The solder alloy (wt.%) ... **63Sn-37Pb (Sn-Pb)**
- ◆ Soldering times (seconds) and temperatures (°C):

	15s	60s	120s
215°C			
240°C			
260°C			
290°C			

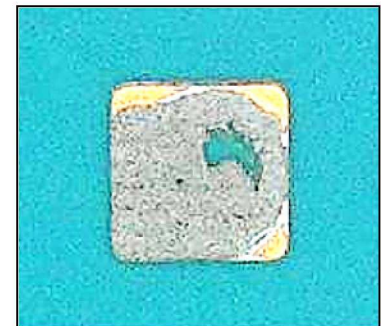
* *DuPont™ is a registered trademark of E.I. DuPont de Nemours Corp., Wilmington, DE.*

Experimental Procedure

- ◆ The pin pull test was performed at **10 mm/min**.
- ◆ Eight (8) of nine (9) pins were pull tested on duplicate test specimens per condition, for a total of **sixteen (16) data points**.
- ◆ Fracture mode analysis is a *critical* step in this study.
 - There were four predominant failure modes:

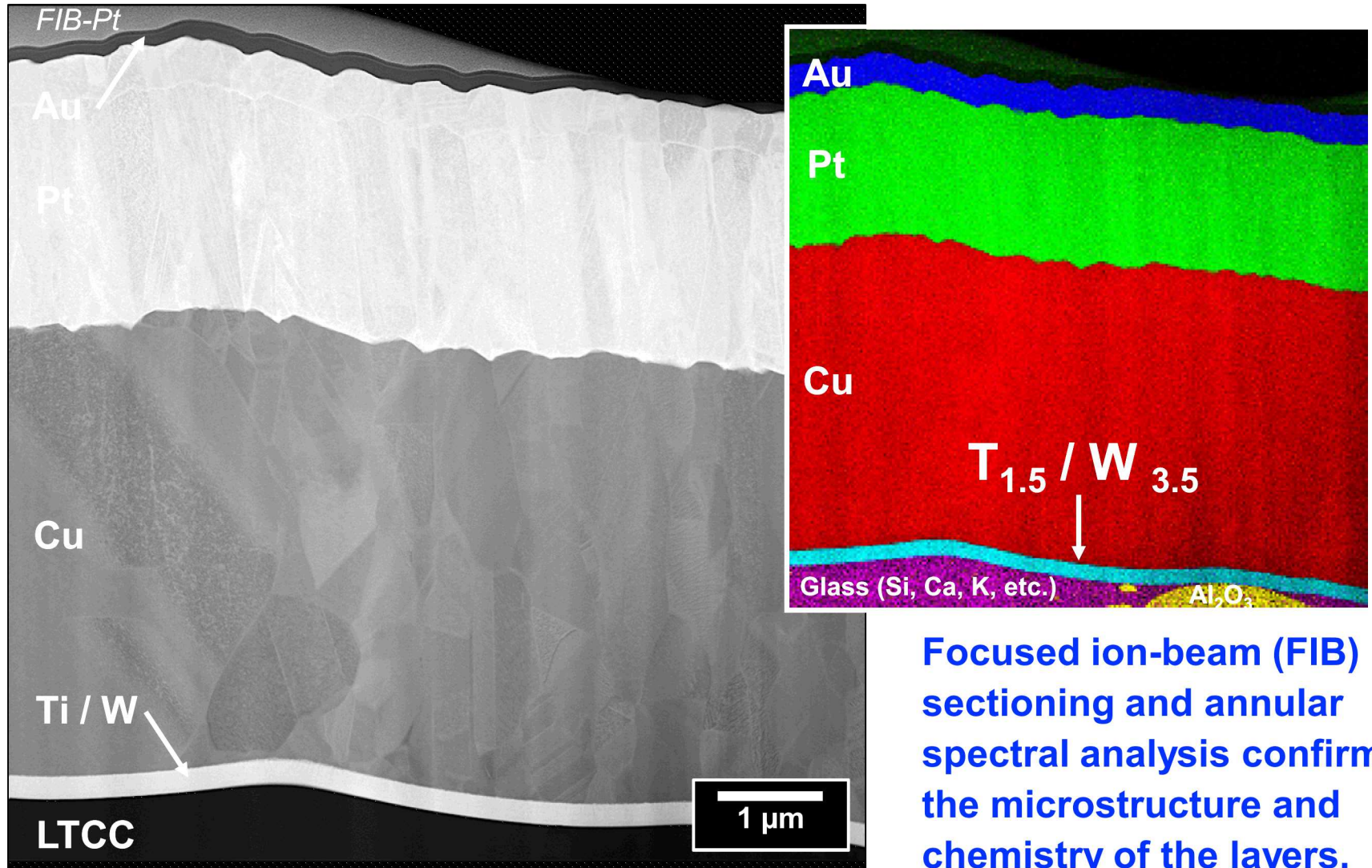


Thin film peeling



Results – Analysis of the Ti/W – Cu – Pt – Au Thin Film

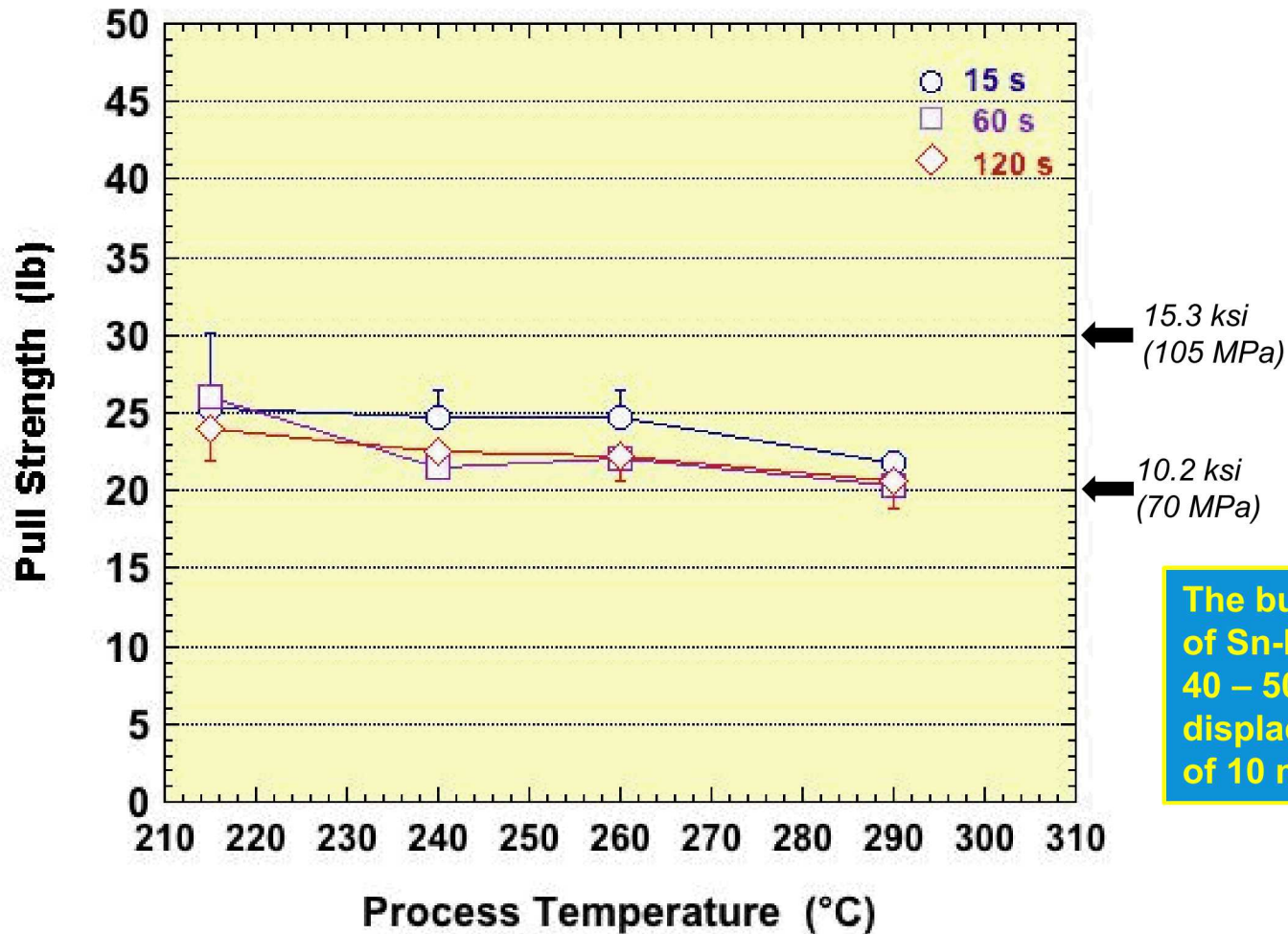
- ◆ Microanalysis methods documented the thin film structure.



Focused ion-beam (FIB) sectioning and annular spectral analysis confirmed the microstructure and chemistry of the layers.

Results – Pull Strengths of the Sn-Pb Solder Joints

- ◆ The pull strengths are shown as a function of soldering temperature.

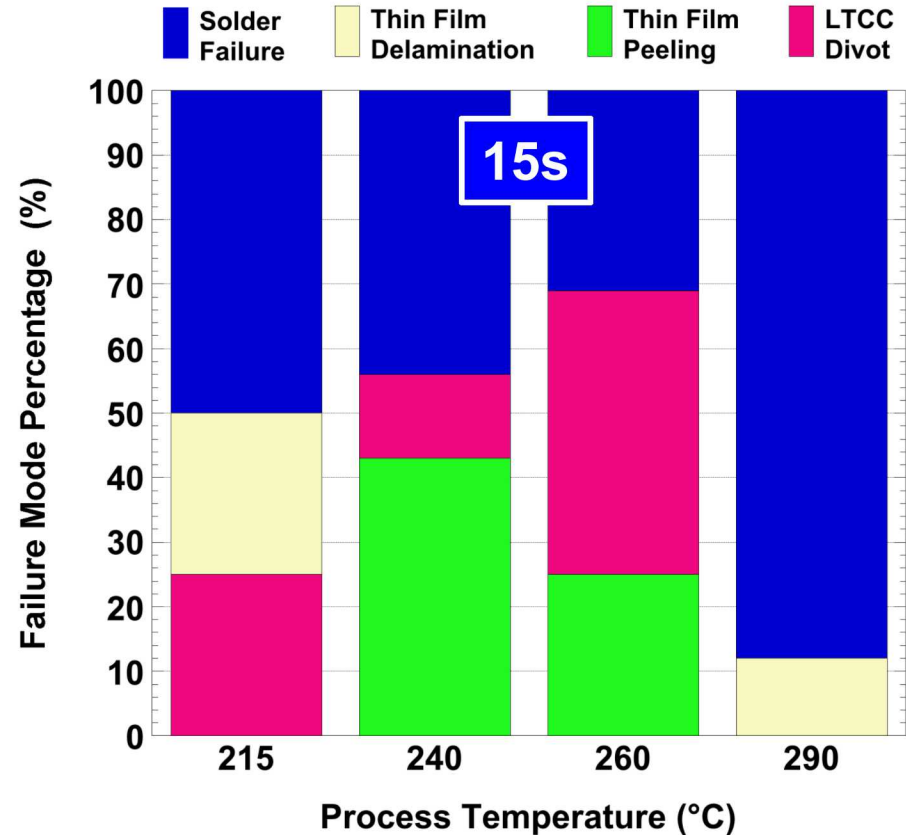
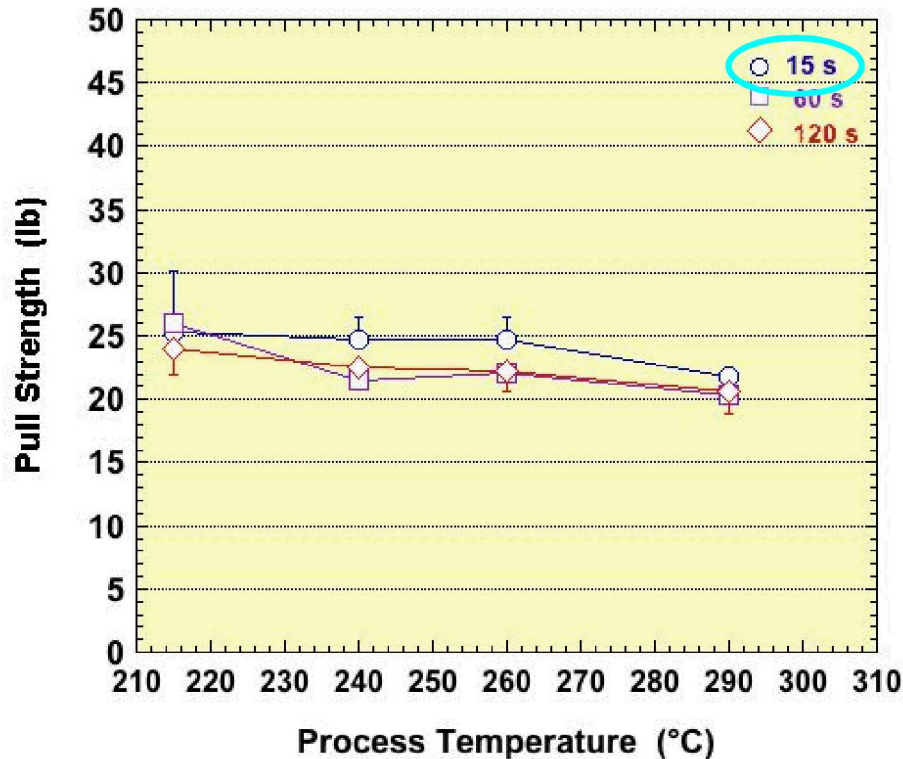


The bulk strength of Sn-Pb solder is 40 – 50 MPa at the displacement rate of 10 mm/min.

- ◆ The 60 s and 120 s values were lower than 15 s at 240°C and 260°C.

Results – Failure Mode Analysis – 15 s

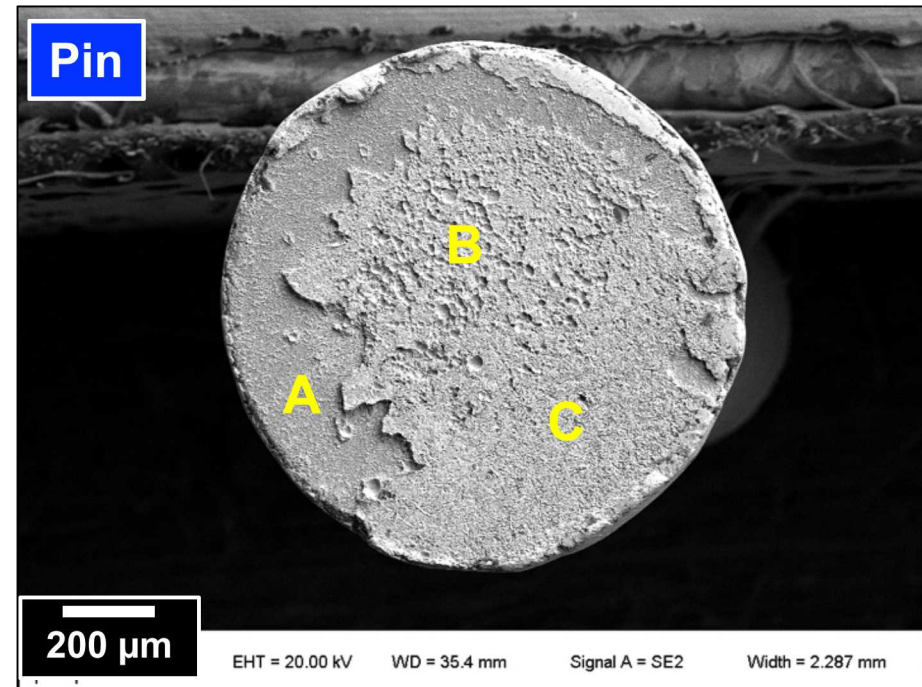
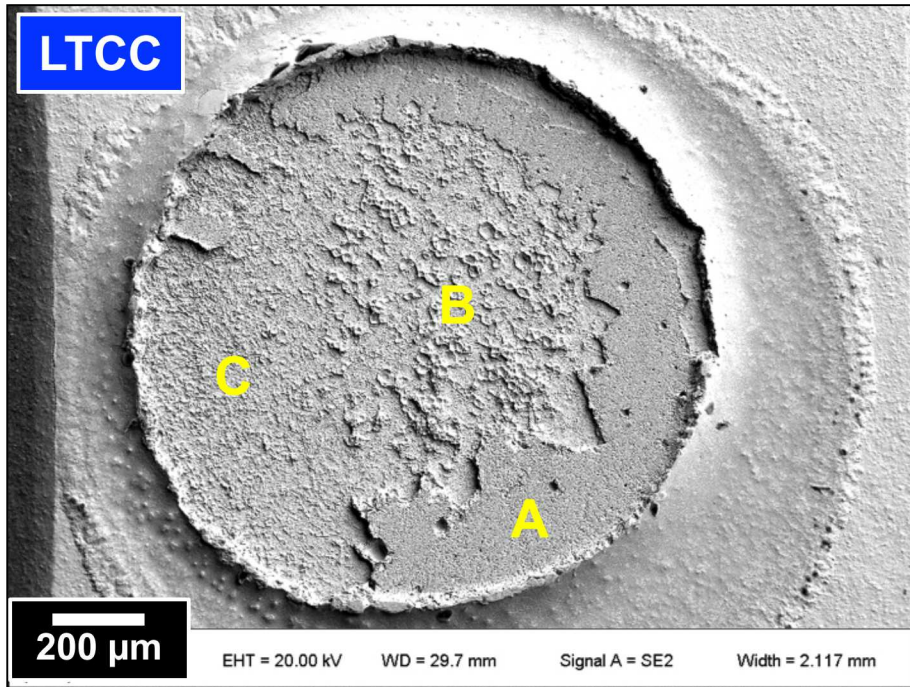
- ◆ The pull strengths were correlated to the failure mode trends.



- 215°C – 260°C: *significant failure mode change accompanied the relatively limited changes in pull strength.*
- 290°C: *solder failure dominated the fracture surfaces.*

Results – Failure Mode Analysis – 15 s

- ◆ The SEM images show matching surfaces of the **solder failure** mode.
- ◆ Three morphologies **A**, **B**, and **C** characterized the fracture surfaces.

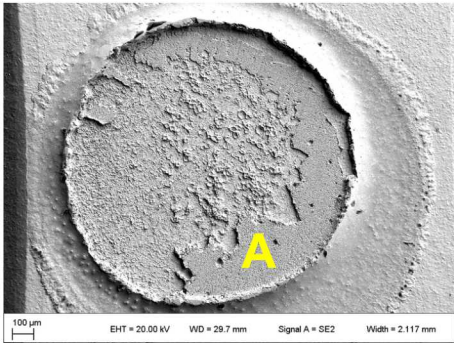


(9051301-08, As-fab 215°C; 15 s; C1)

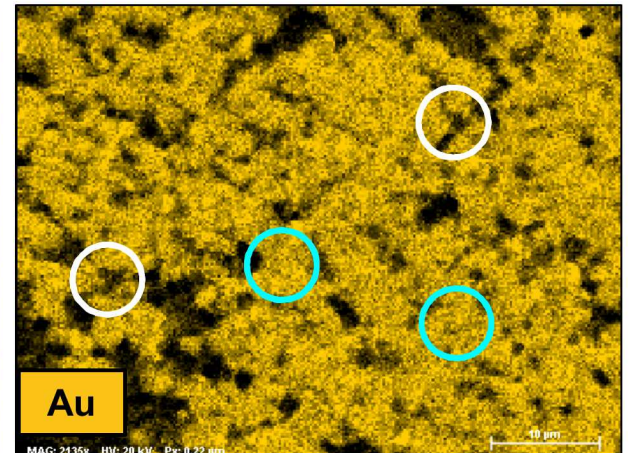
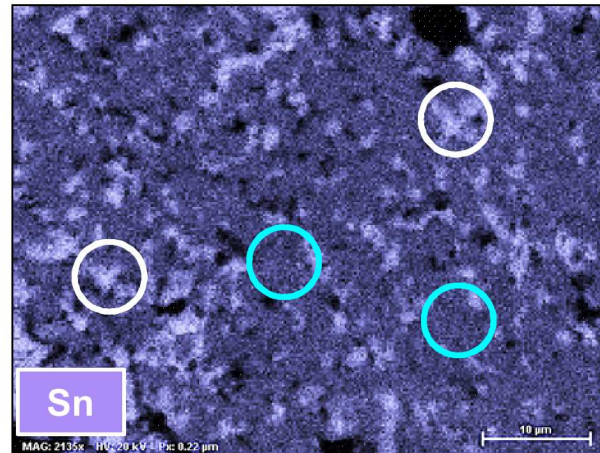
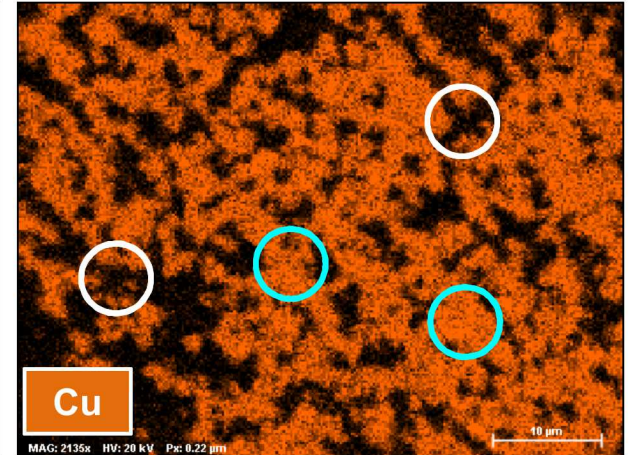
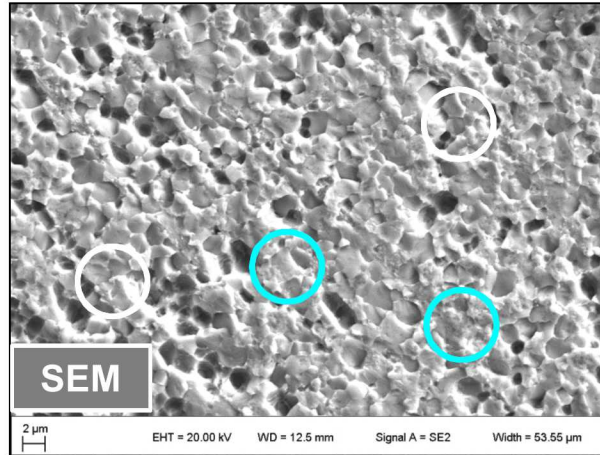
- ◆ Energy dispersive x-ray (EDX) analysis was used to determine the chemical signatures of the fracture surfaces.

Results – Failure Mode Analysis – 15 s

- ◆ **Area A** has an intergranular morphology, indicating *brittle fracture*.



(9051301-08, As-fab 215°C; 15 s; C1)



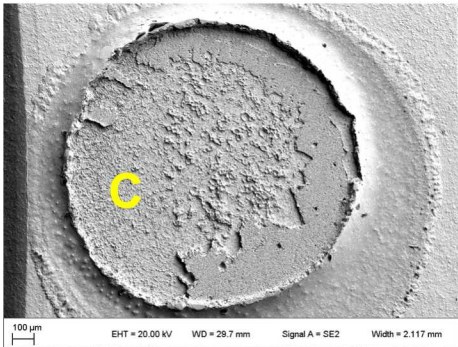
○ Sn, only

○ (Au, Cu)_xSn_y
intermetallic
compound (IMC)

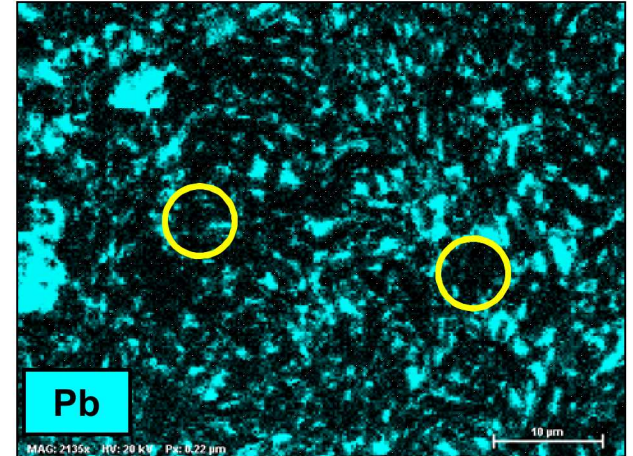
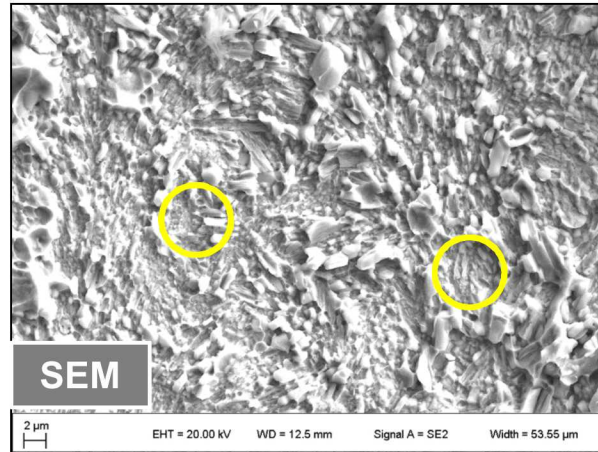
- ◆ The *same morphology and chemistries* were observed on the pin.

Results – Failure Mode Analysis – 15 s

- ◆ **Area C** exhibited more deformation, indicating a *ductile fracture*.

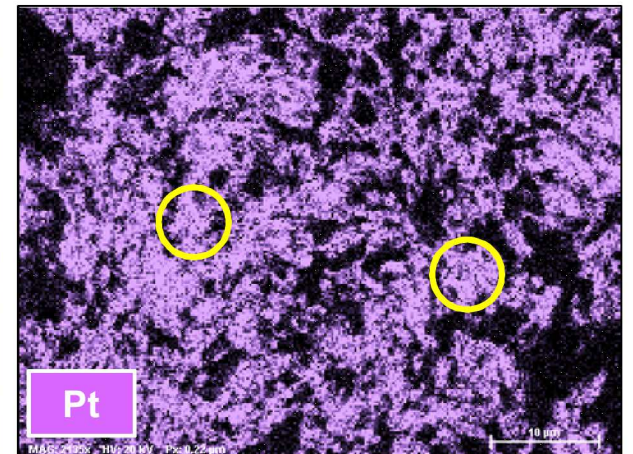
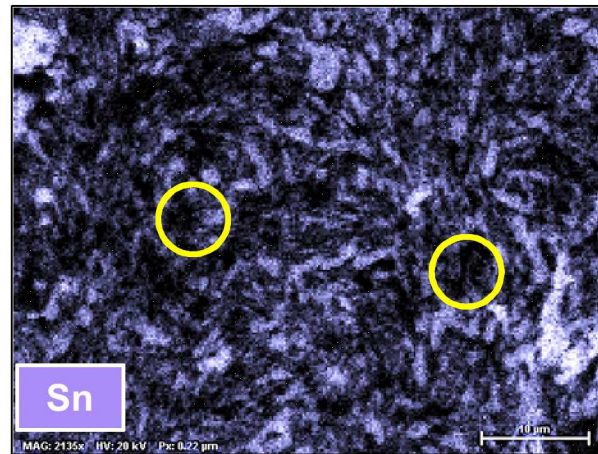


(9051301-08, As-fab 215°C; 15 s; C1)



○ Largely 100Pt

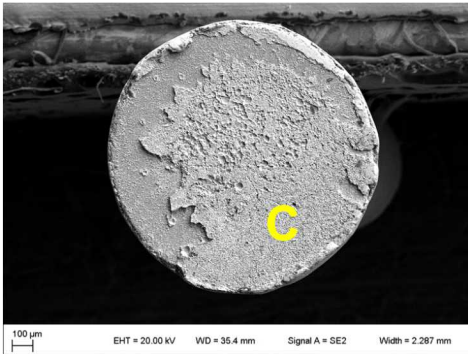
*Islands of 100Pb
are also present.*



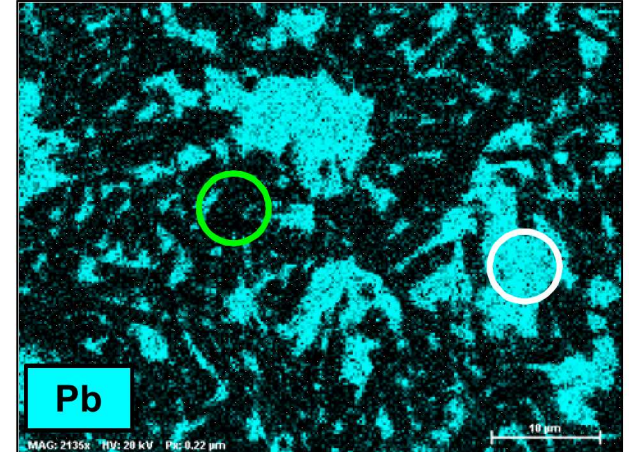
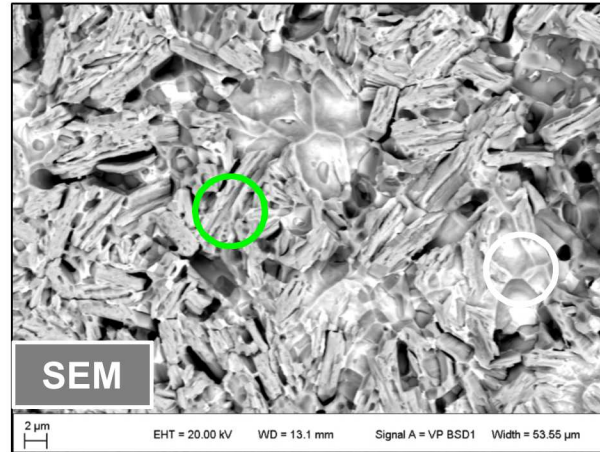
- ◆ **Area B** was similar to area C, but with more Pb-rich phase.

Results – Failure Mode Analysis – 15 s

- ◆ The corresponding **Area C** was examined **on the pin**.

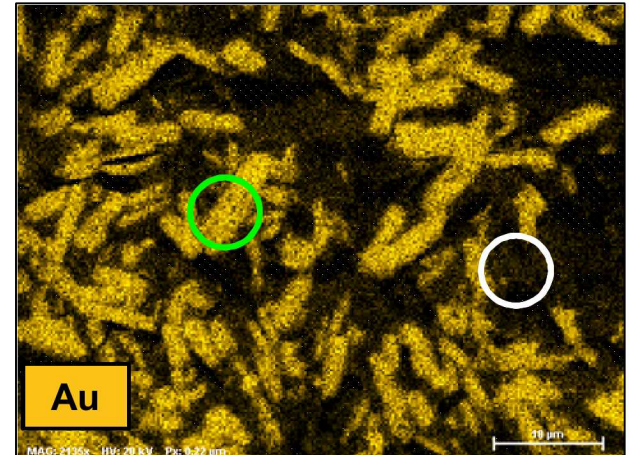
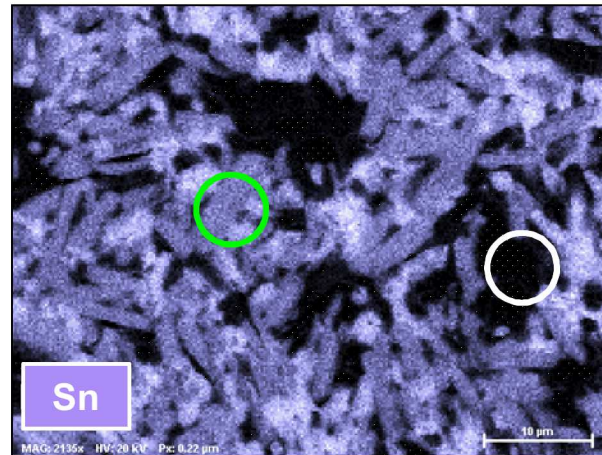


(9051301-08, As-fab 215°C; 15 s; C1)



○ Au_xSn_y IMC

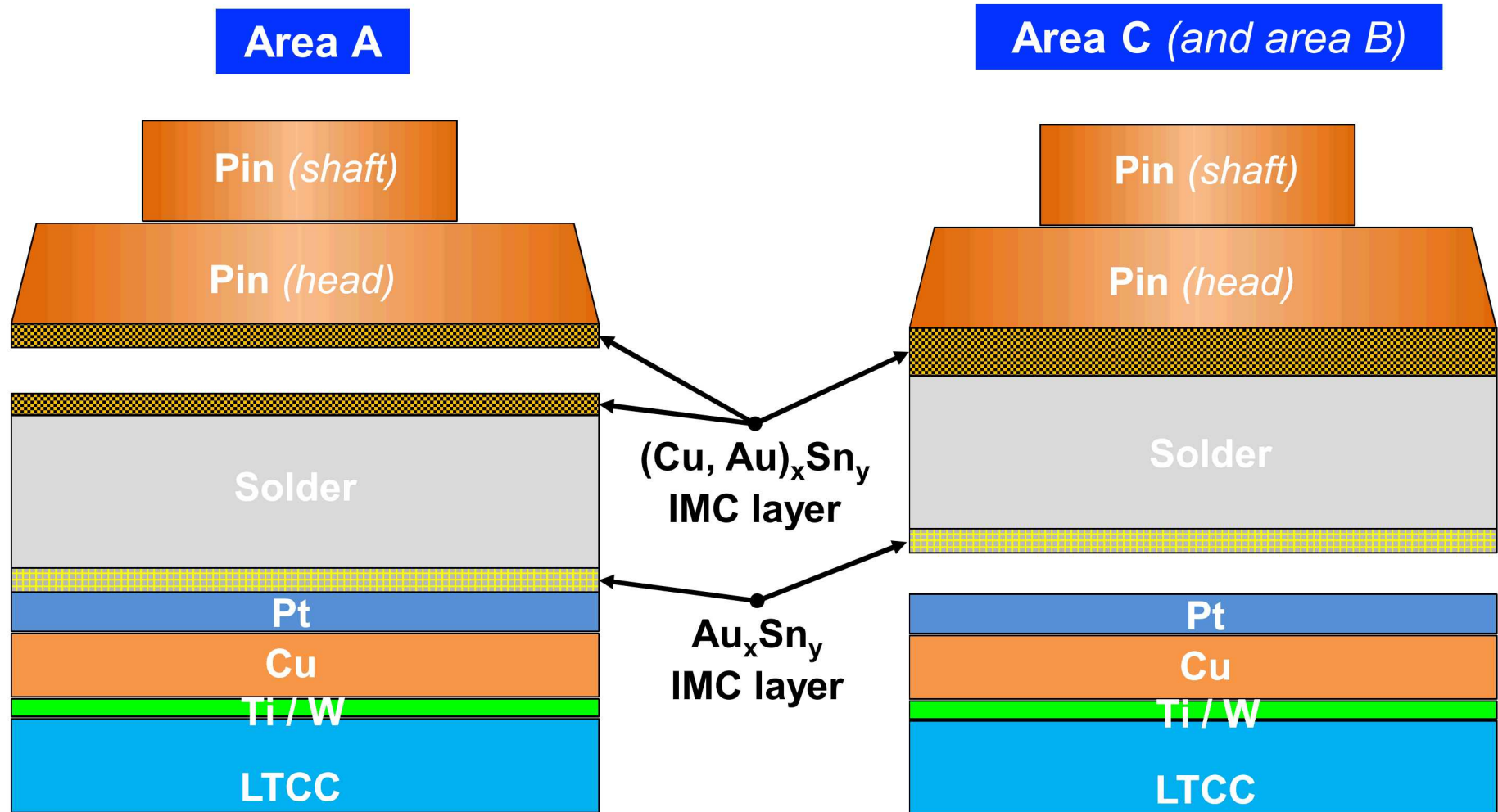
100Pb



- ◆ The fracture **area C** showed a crystalline morphology **on the pin**.

Results – Failure Mode Analysis – 15 s

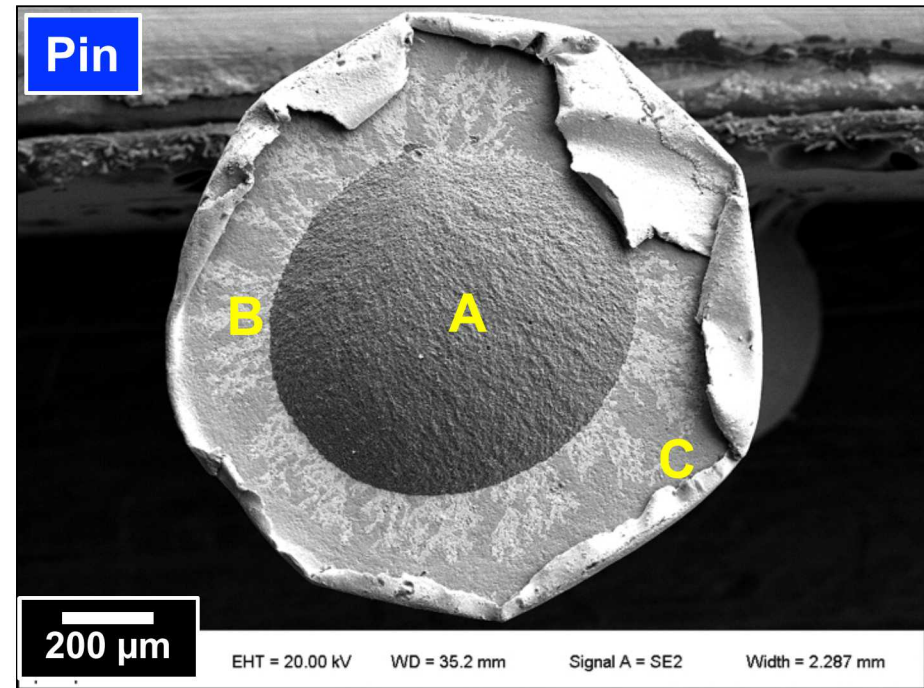
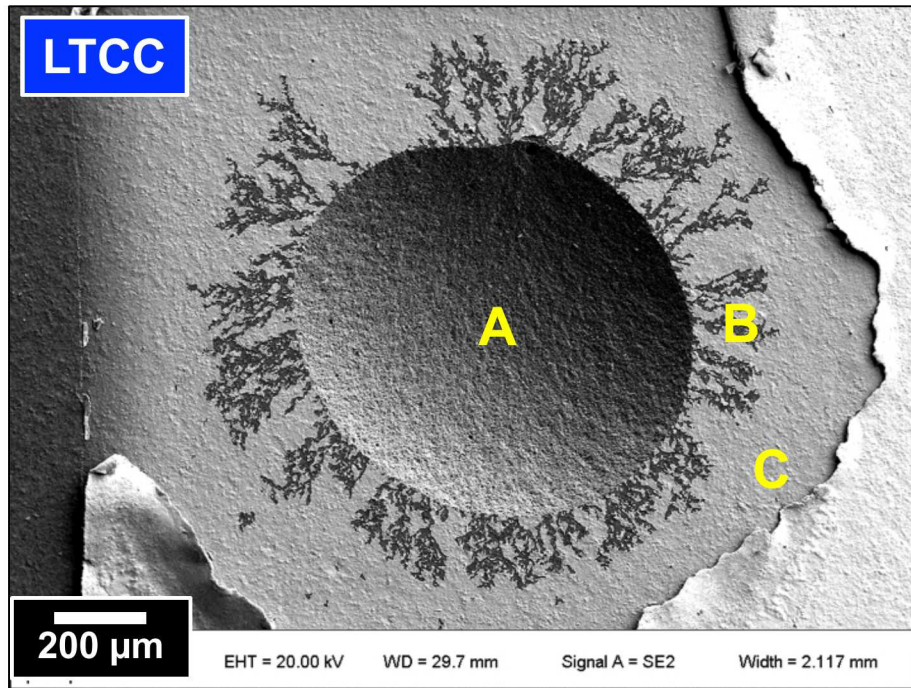
- ◆ The **crack paths** are illustrated by these schematic diagrams.



Results – Failure Mode Analysis – 15 s

◆ The **divot failure** exhibited three crack paths.

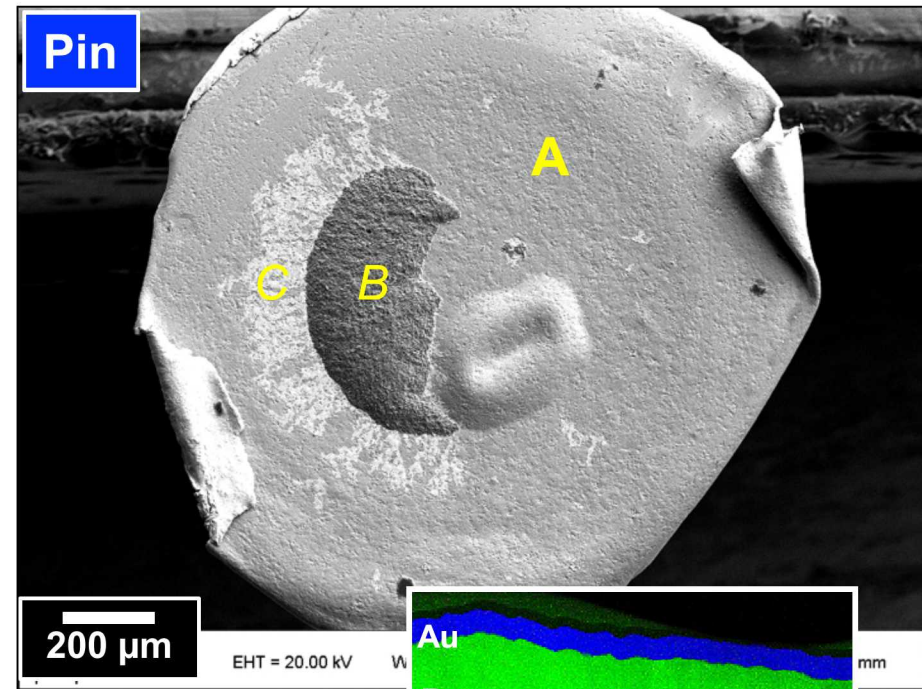
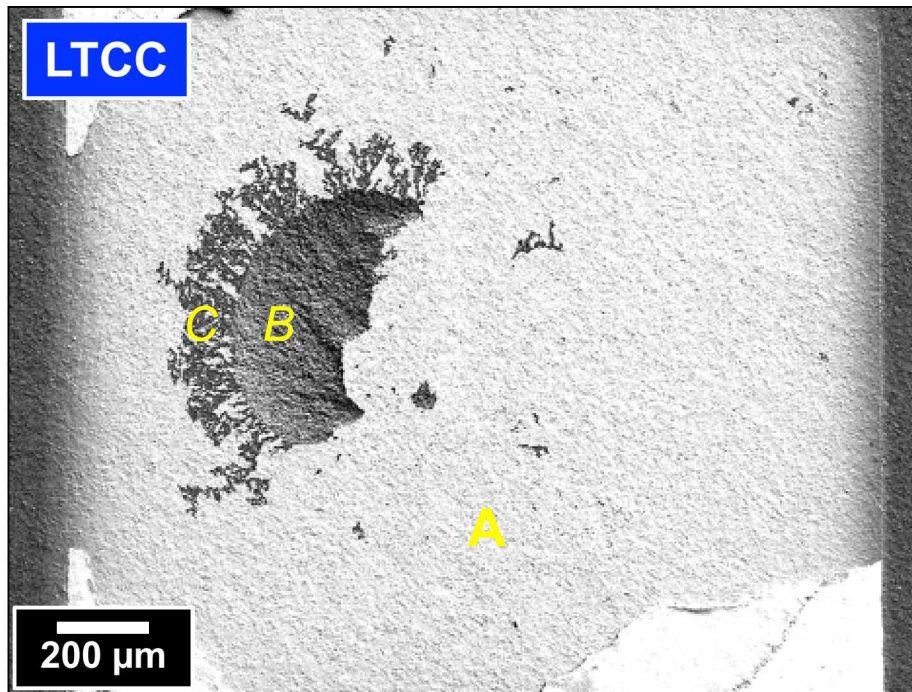
- A ... bulk fracture in the LTCC
- B ... combination of thin film delamination and peeling
- C ... thin film delamination



(9051301-08, As-fab 215°C; 15 s; C1)

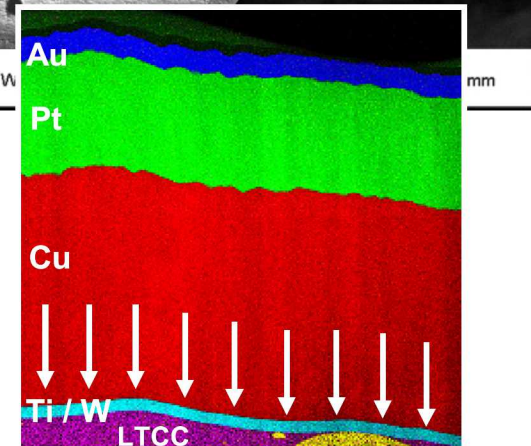
Results – Failure Mode Analysis – 15 s

- ◆ Thin film peeling failure (A) was caused by fracture *within* the film.



9091325-32, As-fab 245°C; 15 s; C1

- ◆ The EDX analysis determined that separation occurred, specifically, at the **Ti/W - Cu interface**.



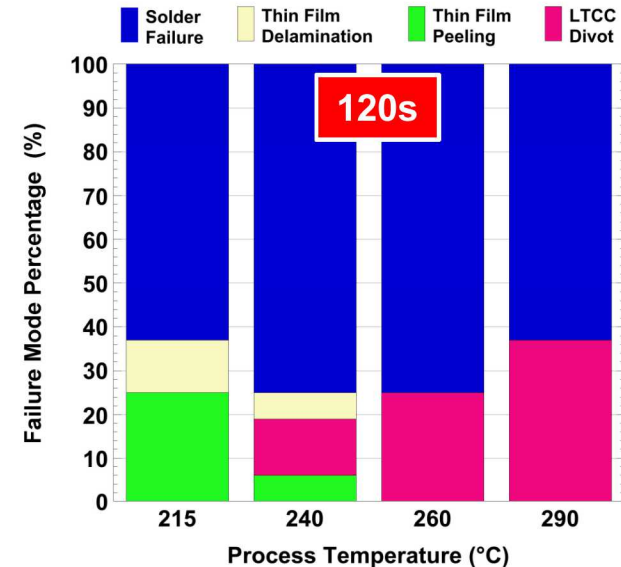
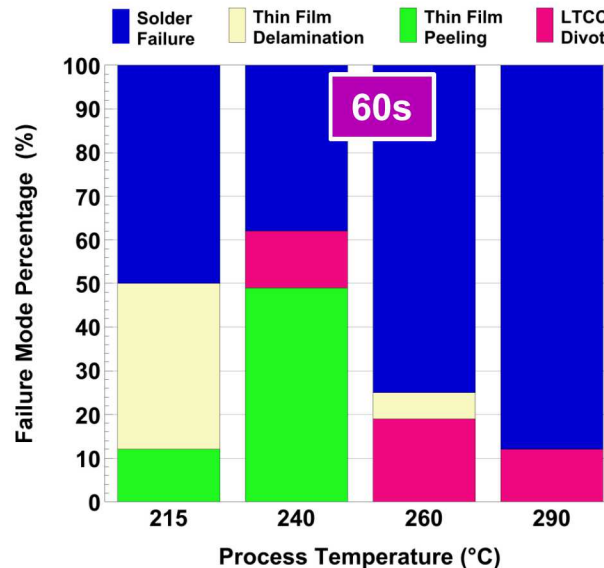
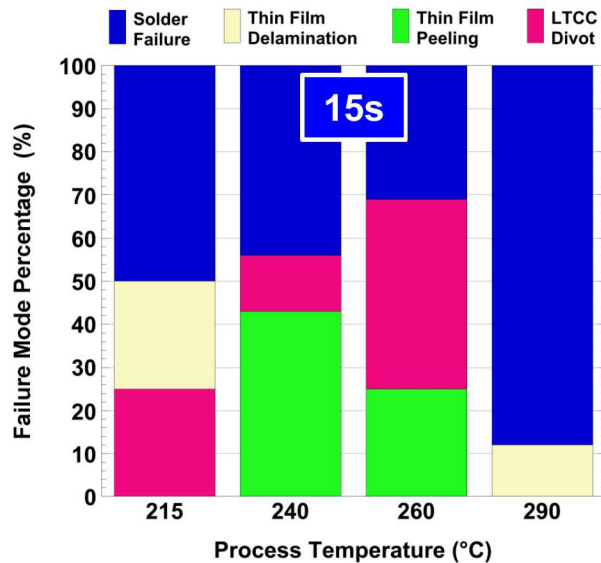
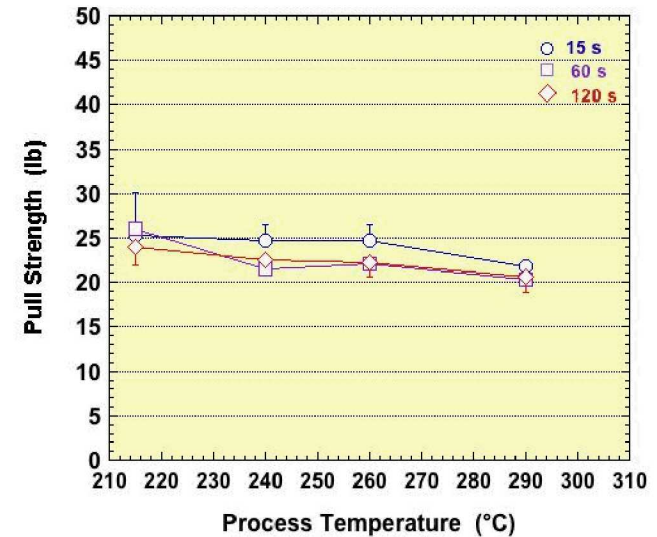
Results – Failure Mode versus Strength

◆ The three failure modes:

- Thin film delamination
- Thin film peeling
- LTCC divots

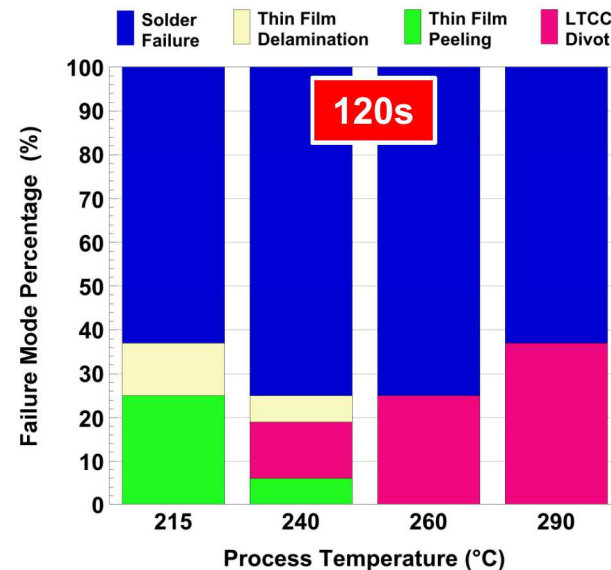
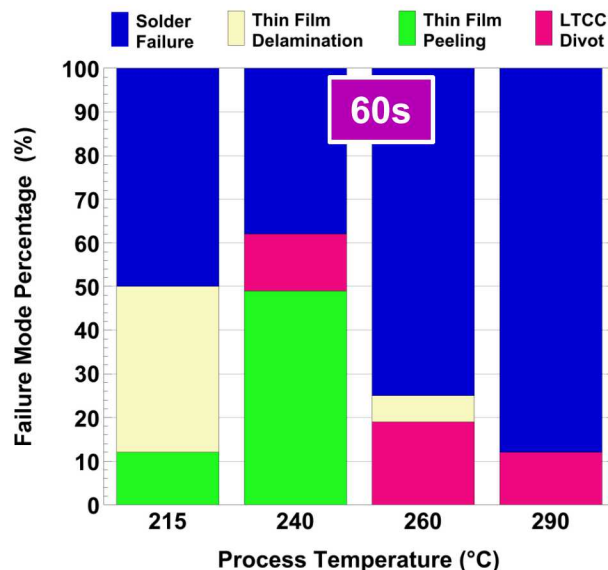
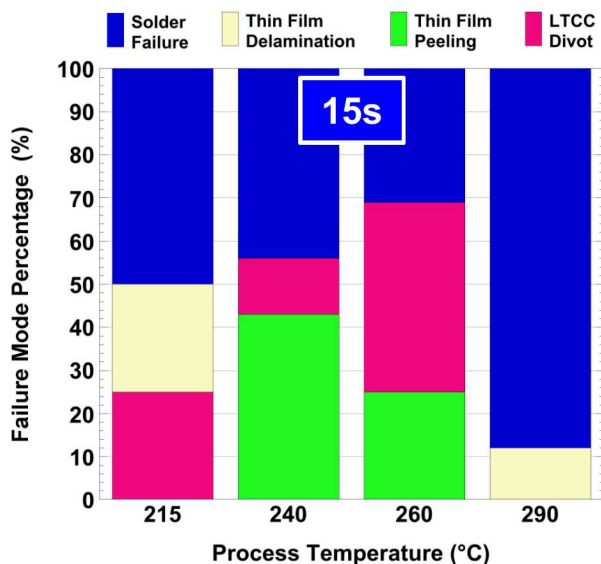
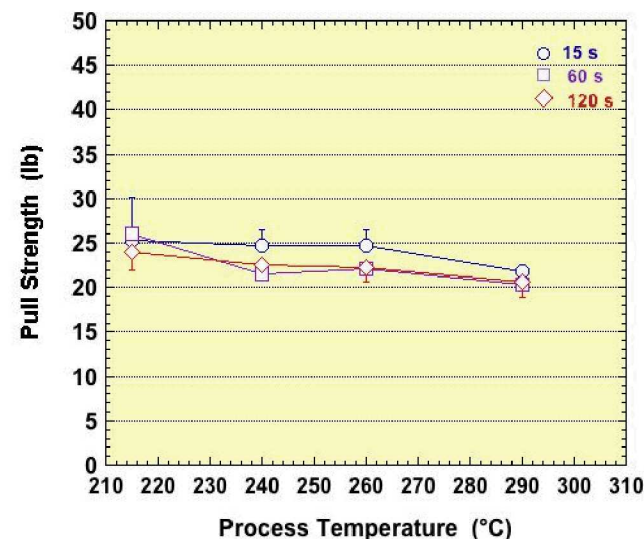
did not correlate with the strength trends.

◆ These failure modes shifted to the lower process temperatures and lesser presence.



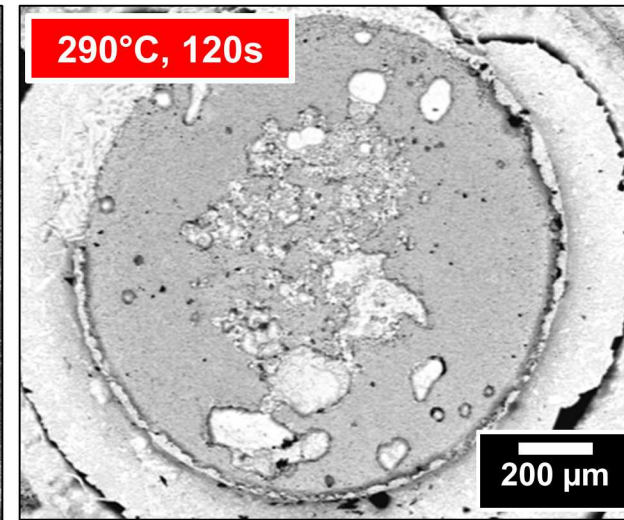
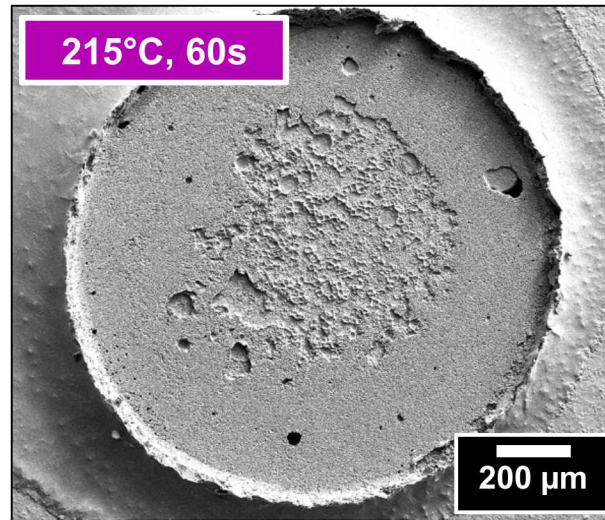
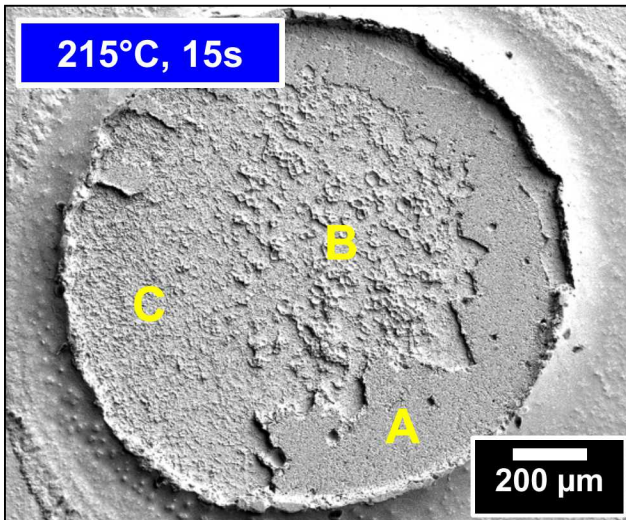
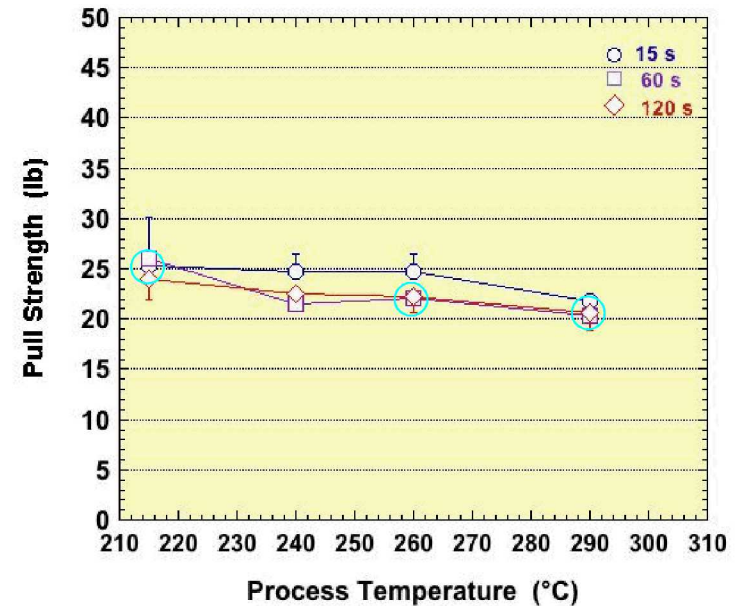
Results – Failure Mode versus Strength

- ◆ The **solder failure mode** exhibited a significant presence at 290°C, 15s
- ◆ As soldering time durations increased, the solder failure mode became *more prevalent at lower soldering temperatures*.
- ◆ The increase of the solder failure mode generally correlated to a loss of strength.



Results – Failure Mode versus Strength

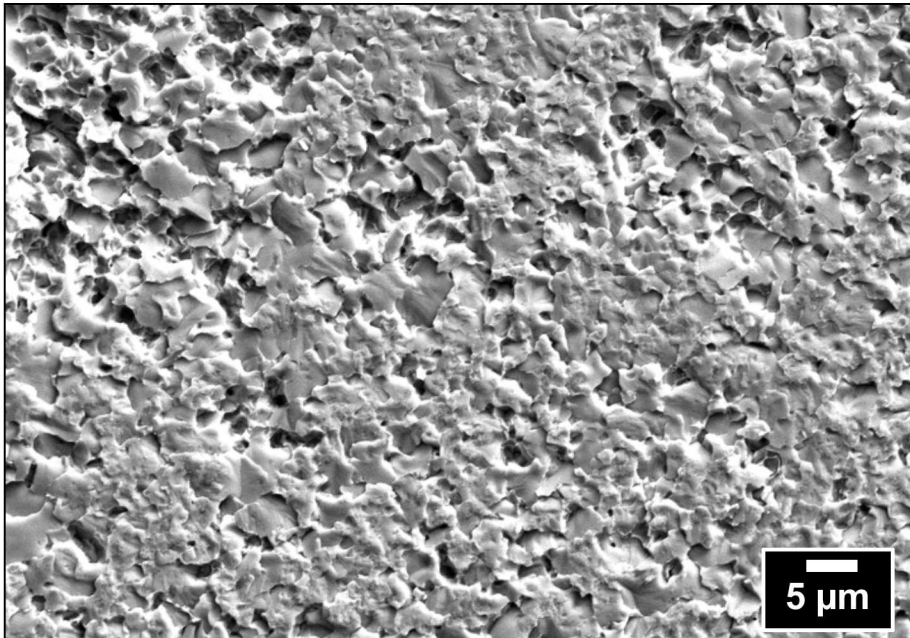
- ◆ The strength decrease, albeit small, was accompanied by a change in the fracture surface morphology.
- ◆ The fracture surface, “A”, increased in extent with the “severity” of the soldering process.
 - Area “A” was separation within the $(\text{Cu}, \text{Au})_x\text{Sn}_y$ IMC layer at the Cu pin.



Results – Failure Mode versus Strength

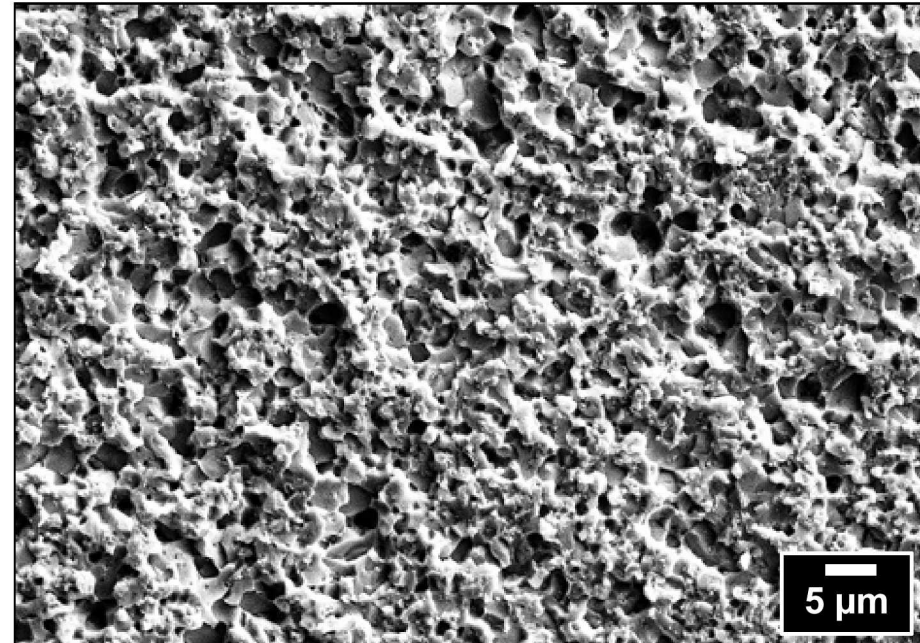
- ◆ The “A” fracture surface changed on the micro-scale.

215°C, 60s



7241303, As-fab 215°C; 60 s; Al

290°C, 120s



7301303, As-fab 290°C; 120 s; Al

The increased surface relief was caused by further growth of the $(\text{Cu}, \text{Au})_x\text{Sn}_y$ IMC layer at the Cu pin side of the joint.

Summary

- ◆ A study was performed to evaluate the tensile strength of **Sn-Pb solder joints** made to **0.20Ti/W - 4.0Cu - 2.0Pt - 0.38Au (μm)** thin films on **low-temperature, co-fired ceramic (LTCC)** substrates.
- ◆ The strength performance was evaluated as a function of soldering time and temperature process parameters.
- ◆ Pin pull strengths remained excellent, across the process conditions.
- ◆ Four failure modes were identify on the fracture surfaces.
 - Solder failure
 - Thin film delamination
 - Thin film peeling
 - LTCC divots

Summary

◆ The latter three failure modes:

- Thin film delamination
- Thin film peeling
- LTCC divots

... did not correlate with the pull strength trends.

- The absence of any trend implied that the associated structures had *comparable, intrinsic strength levels*.

◆ The strength decrease correlated with the **solder failure mode**.

- The strength loss was associated with an increased presence of *fracture in the $(\text{Cu}, \text{Au})_x\text{Sn}_y$ IMC layer* that developed at the Cu pin side of the Sn-Pb solder joint.